IFX Day 2004

November 16, 2004 - Munich

Manufacturing Update

Dr. Andreas von ZitzewitzChief Operating Officer



Never stop thinking.



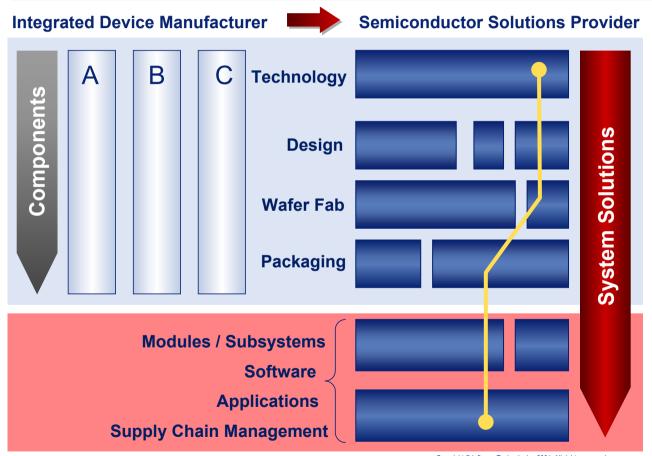
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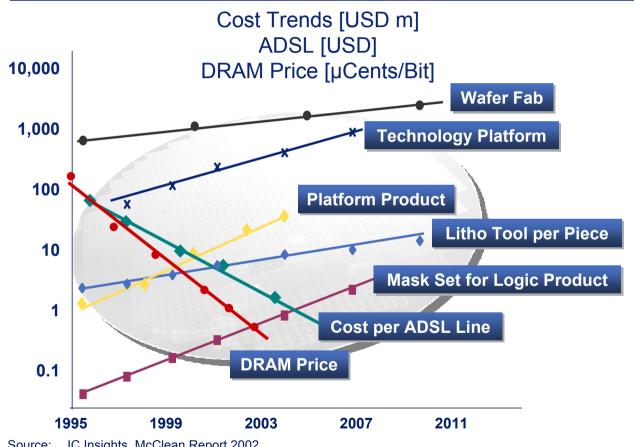
From an Integrated Device Manufacturer (IDM) to a Semiconductor Solutions Provider (SSP)



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Increasing cost require collaboration to keep development and investments affordable



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IC Insights, McClean Report 2002,

Semiconductor Business News 01/07/03



Business benefits of partnerships and outsourcing

Partnerships

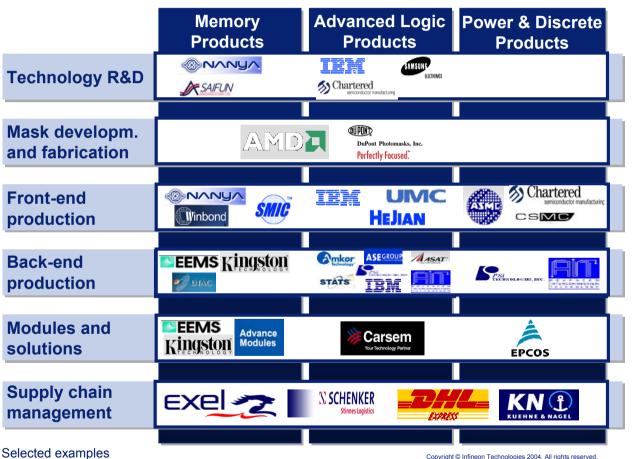
- Access to additional IP, resources, and production capacity
- Cost sharing
- Reduced risks
- Extended portfolio
- Lower capital intensive strategy

Outsourcing

- Flexibility
- Extended portfolio
- No assets



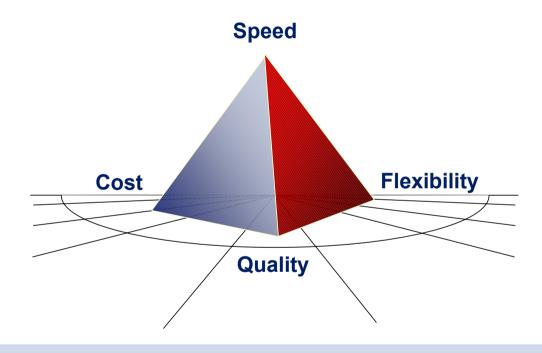
Infineon's network of manufacturing partnerships



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Speed, cost, quality, and flexibility are key success factors for manufacturing excellence

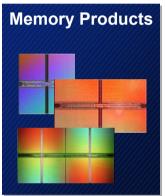


The four key success factors are linked together and can not be optimized independently



Infineon Manufacturing Clusters

















One virtual fab to our customers



Memory Products manufacturing cluster



Memory Cluster

Front-end









Winbond

Identical technology roadmaps

Global process synchronization and quality control

Best-practice sharing and fast ramps

Backend















Memory's 300mm production roadmap





Infinean Producting first

Inotera, JV Taiwan







■ **Dresden:** Already ramped to > 30k WSPM on 110nm

■ Inotera: Currently ramping 110nm (act. > 24k WSPM)

■ Richmond: Currently equipping fab shell (ramp 2nd HY05)

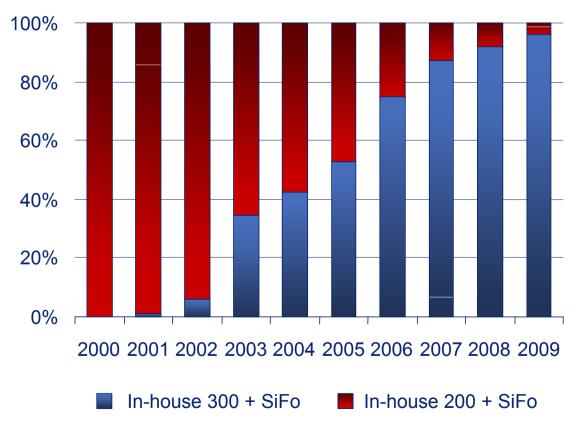
■ Foundries: SMIC 300 ramping, WIN 300 construction

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Memory manufacturing: Evolution of 300mm volumes





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Advanced Logic front-end cluster



Advanced Logic Cluster











250nm Al

Synergy from cooperation in R&D and manufacturing

180nm Cu

Common technology platforms

130nm Cu

Reduced investment and mutual sharing of capacity

90nm Cu

Mutual compensation for fluctuating logic demand

65nm Cu

Best-practice sharing and fast ramps

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Power logic front-end cluster



Power logic cluster









One organisation for R&D and in-house manufacturing

Common technology platforms

Reduced investment and sharing of capacity

Cost efficient manufacturing

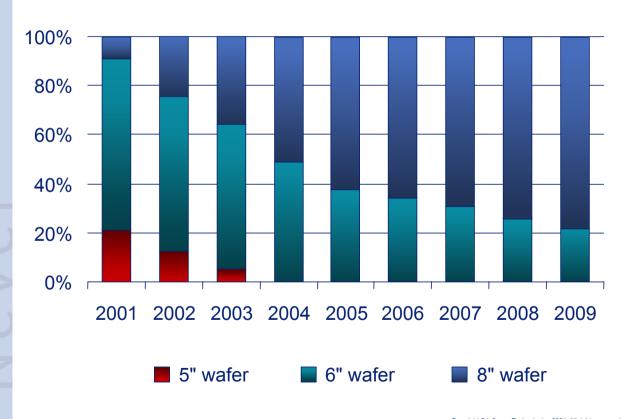
Best practice sharing and fast ramp-ups

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Power Logic: Evolution of wafer diameters



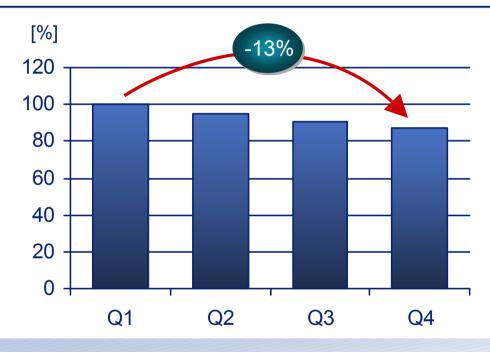


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Evolution of 8" cost per mask layer in logic front-end production in FY03/04





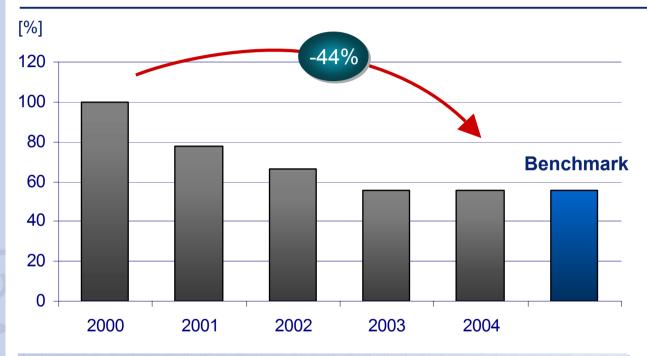
Cost reduction due to

- Increased logic share in Dresden 200mm
- Productivity improvements in power logic fabs and Altis



Speed: Evolution of cycle-times in logic front-end production





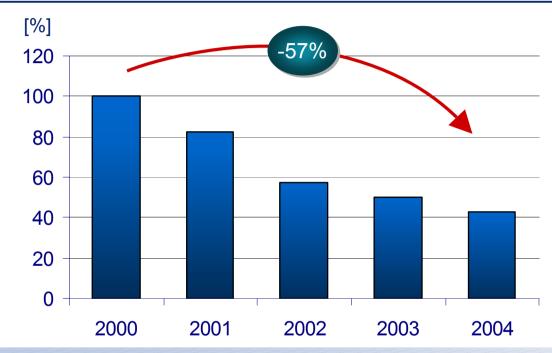
Reduction of cycle times by ~2x compared to 2000

- Faster yield learning
- Increased delivery flexibility: "Serve the Market"



Speed: Evolution of range in back-end production





Reduction of BE range by > 2x compared to 2000:

- Reduced stock levels
- Faster cycle time and increased delivery performance

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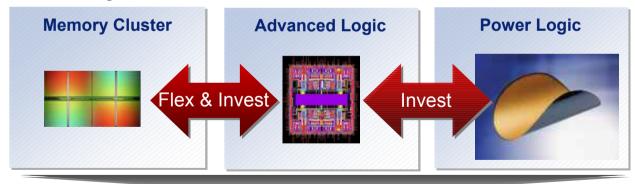


Integrated manufacturing to maximized flexibility and minimized cost



Maximize: Opportunities during market upturns Minimize: Impact of downturns and investments

- Internal flexibility: Between MP and Advanced Logic Cluster
- External flexibility: Silicon foundries and subcontractors
- Cost optimization: Reuse of depreciated equipment for power technologies



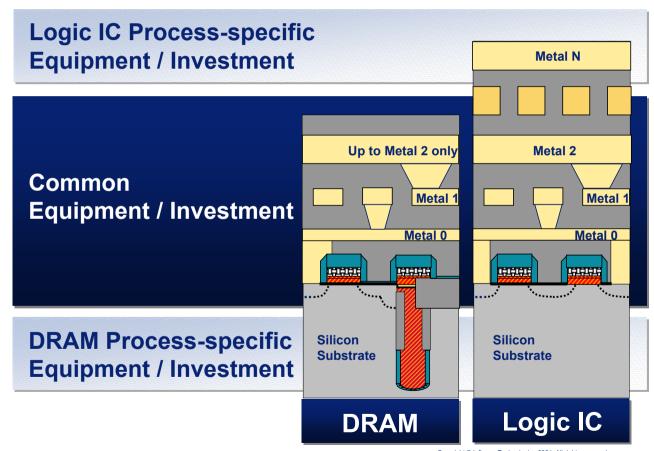
Flexibility: Silicon foundries and subcontractors

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Flexibility: Extended equipment sharing between Memory and Logic Manufacturing





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Flexibility between memory and logic as an operational and strategic concept



Operational advantages

- Memory as a forerunner in lithography and advanced tool learning
- Memory as ramp-up and volume vehicle with excellent debug capabilities to tune and stabilize processes (logistics, equipment, utilization, technologies)
- Memory production optimizes manufacturing processes: Ramp-up of new manufacturing sites and teams
- Memory volume buffers fluctuations in logic IC demand, and improves capital efficiency of our fabs
- Flexible and gradual cascading of fabs from memory to logic IC fabrication (currently 200mm in Dresden)
- Cascading of depreciated equipment from memory and Advanced Logic to Power Logic Fabs reduces capex required for growth





Never stop thinking.